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REMARKS

Claims 1 to 28 are pending. No claims are allowed.

Independent claims 1, 19 and 20 have been amended to call for the substrate having first and second major faces with the cathode active material provided on both of them as a physical vapor deposited layer. This amendment is believed to overcome U.S. Patent No. 5,569,588 to Takeuchi et al. (column 4, lines 7 to 10) and 5,616,429 to Klementowski (column 2, lines 50 to 54). The claim amendments have previously been discussed with the Examiner as being sufficient to overcome the above prior art patents.

It is believed that claims 1 to 28 are now in a condition for allowance. Notice of Allowance is requested.

Respectfully submitted,


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